

Low-cost microscope projection photolithography system for high-resolution fabrication

CHINA, December 2, 2023 /EINPresswire.com/ -- A research team developed a low-cost and easy-toimplement microscope projection photolithography system using off-theshelf components for rapid and highresolution fabrication of micro- and nanostructures. Even with economic microscope objectives, the system can achieve feature sizes down to sub-100 nm. This technology extends the capabilities of photolithography and



may find applications in nanophotonics, biophotonics sensing, and material science.

Integrated optical signal distributing, processing, and sensing networks require the miniaturization of basic optical elements, such as waveguides, splitters, gratings, and optical switches. To achieve this, fabrication approaches that allow for high-resolution manufacturing are required. Curved elements like bends and ring resonators are especially challenging to fabricate, as they need even higher resolution and lower sidewall roughness. Additionally, fabrication techniques with precise control of absolute structure dimensions are imperative.

Several technologies have been developed for subwavelength high-resolution manufacturing, such as direct laser writing, multi-photon <u>lithography</u>, electron beam lithography, ion beam lithography, and domino lithography. However, these technologies are costly, complex, and time-consuming. Nanoimprint lithography is an emerging replication technique well-suited for high-resolution and efficient manufacturing. However, it requires high-quality master stamps, which are usually produced using electron beam lithography.

In a new paper published in Light: Advanced Manufacturing, scientists Dr.-Ing. Lei Zheng et al. from the Leibniz University Hannover have developed a low-cost and user-friendly fabrication technique, called UV-LED-based microscope projection photolithography (MPP), for rapid highresolution manufacturing of optical elements within seconds. This approach transfers structure patterns on a photomask to a photoresist-coated substrate under UV illumination. The MPP system is based on standard optical and optomechanical elements. Instead of a mercury lamp or a laser, an extremely low-cost UV-LED with a wavelength of 365 nm is used as the light source.

The researchers developed a preceding process to obtain the structure-patterned chromium mask required in MPP. It includes structure design, printing on a transparent foil, and the pattern transfer onto the chromium photomask. They established a lithography setup for the preparation of photomasks as well. Structure patterns printed on the transparent foil can be transferred to a chromium photomask with this setup and a subsequent wet-etching process.

The MPP system can fabricate high-resolution optical elements with feature sizes down to 85 nm. This is comparable to the resolution of much more expensive and complex fabrication methods, such as multi-photon and electron beam lithography. MPP could be used to fabricate microfluidic devices, biosensors, and other optical devices.

This fabrication approach developed by the researchers is a significant advancement in the field of lithography for the rapid and high-resolution structuring of optical elements. It is particularly well-suited for applications where rapid prototyping and low-cost fabrication are important. For example, it could be used to develop new optical devices for biomedical research or to prototype new MEMS devices for consumer electronics applications.

DOI 10.37188/lam.2023.033

Original Source URL https://doi.org/10.37188/lam.2023.033

Funding information This work was supported by the German Research Foundation (DFG) under Germany's Excellence Strategy within the Cluster of Excellence PhoenixD (EXC 2122, Project ID 390833453).

Lucy Wang BioDesign Research email us here

This press release can be viewed online at: https://www.einpresswire.com/article/672389436

EIN Presswire's priority is source transparency. We do not allow opaque clients, and our editors try to be careful about weeding out false and misleading content. As a user, if you see something we have missed, please do bring it to our attention. Your help is welcome. EIN Presswire, Everyone's Internet News Presswire[™], tries to define some of the boundaries that are reasonable in today's world. Please see our Editorial Guidelines for more information. © 1995-2023 Newsmatics Inc. All Right Reserved.